

Supplemental data:

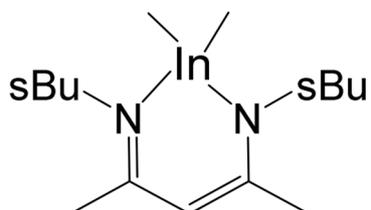
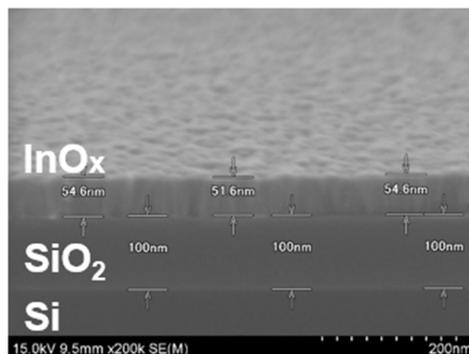


Fig.1 Chemical structure of DK1-6



Thickness: 53.6 nm
GPC: 0.536 Å/cycle

Fig.2 FESEM image of ALD In_2O_3 film using DK1-6 and O_3 co-reactant at 300°C

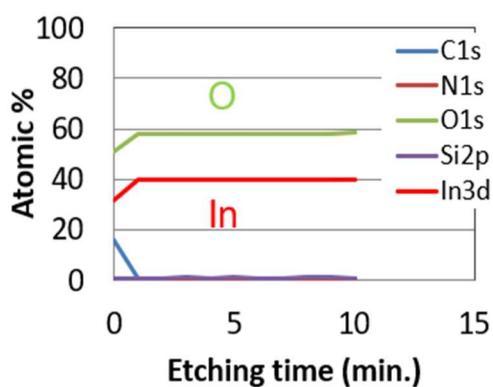


Fig.3 XPS depth profile of ALD In_2O_3 film using DK1-6 and O_3 co-reactant at 300°C

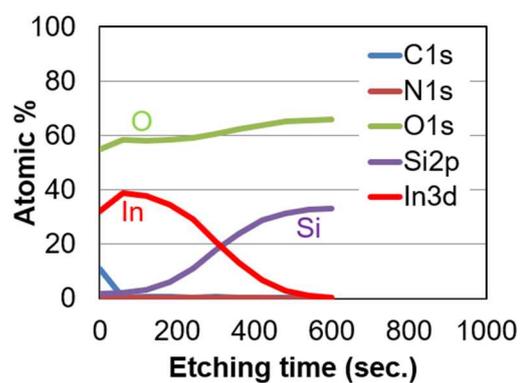


Fig.4 XPS depth profile of ALD In_2O_3 film using DK1-6 and H_2O co-reactant at 300°C